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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/731,623	. 12/07/2000	Debora Rinkevich	AUS9-2000-0706-US1	1062
7590 07/26/2005			EXAMINER	
Kelly K. Kordzik			CHAI, LONGBIT	
Suite 800 100 Congress Avenue			ART UNIT	PAPER NUMBER
Austin, TX 78701			2131	
			DATE MAILED: 07/26/2000	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)			
·	09/731,623	RINKEVICH ET AL.			
Office Action Summary	Examiner	Art Unit			
.*	Longbit Chai	2131			
The MAILING DATE of this communication app					
Period for Reply					
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply specified above, the maximum statutory period w Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	6(a). In no event, however, ma within the statutory minimum o rill apply and will expire SIX (6) cause the application to becon	ay a reply be timely filed of thirty (30) days will be considered timely. MONTHS from the mailing date of this communication. ne ABANDONED (35 U.S.C. § 133).			
Status		,			
1) Responsive to communication(s) filed on 28 Ju	ıne 2005.	·			
·- · · · · · · · · · · · · · · · · · ·					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
4) Claim(s) is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) is/are allowed. 6) Claim(s) 1-24 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement.					
Application Papers					
9) The specification is objected to by the Examiner.					
10)⊠ The drawing(s) filed on <u>07 December 2000</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).					
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.					
Priority under 35 U.S.C. § 119					
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 					
Attachmont/c					
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper	ew Summary (PTO-413) No(s)/Mail Date			
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 5) Notice of Informal Patent Application (PTO-152) 6) Other:					

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DETAILED ACTION

Priority

1. No claim for priority has been made in this application.

The effective filing date for the subject matter defined in the pending claims in this application is 12/07/2000.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claim 1 24 are rejected under 35 U.S.C. 103(a) as being unpatentable over Savill (Where can I find a Unix su like utility?) and in view of Wu (U.S. Patent Number 5,774,551), hereinafter referred to as Wu.

As per claims 1, 9 and 17, Savill discloses an authentication method, product and system comprising:

generating a first security context in response to a first user authentication (Savill: Page 1 Line 2: the low privileged account is interpreted as the 1st security context),

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generating a second security context in response to a second user authentication (Savill: Page 1 Line 3: the higher privileged account related to system administrative work is interpreted as the 2nd security context);

However, Savil does not disclose expressly said second security context aggregates said first security context and a security context corresponding to an identity in said second user authentication.

Wu teaches said second security context aggregates said first security context and a security context corresponding to an identity in said second user authentication (Wu: Column 6 Line 65 Column 7 Line 1: stacking multiple authentication services as taught by Wu is interpreted as aggregating first security context into the second security context).

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to combine the teaching of Wu within the system of Savil because (a) Savil discloses the needs of multiple login due to different type of works associated with the same personnel, and (b) Wu teaches providing a simplified login embodiment using <u>automatic</u> multi-login (i.e. unified logon) so that the same personnel need not <u>manually</u> login multiple times for different types of works, which is substantially improves in the ease of use of otherwise complex computer security systems (Wu: Column 3 Line 56 – 57 and Column 4 Line 25 – 28).

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As per claims 2, 10, and 18, Savil as modified teaches the claimed invention as described above (see claim 1, 9 and 17, respectively). Wu further teaches: saving said first security context (Wu: Column 3 Line 56 – 57).

As per claims 3, 11, and 19, Savil as modified teaches the claimed invention as described above (see claim 2, 10 and 18, respectively). Wu further teaches: saving said first security context comprises the step of pushing said first security context on a stack (Wu: Column 6 Line 64 - 67 and Column 7 Line 1 - 4).

As per claims 4, 12, and 20, Savil as modified teaches the claimed invention as described above (see claim 1, 9 and 17, respectively). Savil further teaches: receiving a user logoff (Savil: Page 1 Line 4).

As per claims 5, 13, and 21, Savil as modified teaches the claimed invention as described above (see claim 4, 12 and 20, respectively). Wu further teaches: destroying said second security context in response to said step of receiving said user logoff (Wu: Column 19 Line 60 – 64).

As per claims 6, 14 and 22, Savil as modified teaches the claimed invention as described above (see claim 2, 10 and 18, respectively). Savill teaches reverting to said first security context in response to a user logoff (Savill: Line 1 – 5: Savil teaches allowing the user to just temporarily start the higher privileged account related to system

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administrative work so that the user can avoid closing all open application at logoff – i.e. Examiner notes the low privileged account is still active upon the logoff of temporary higher privileged account related to system administrative work, which is also widely used in the field in UNIX systems).

As per claims 7, 15 and 23, Savil as modified teaches the claimed invention as described above (see claim 6, 14 and 22, respectively). Savill as modified further teaches reverting to said first security context comprises the step of popping said first security context off of a stack (Savill: Page 1 Line 4; Wu: Column 6 Line 65).

As per claims 8, 16, and 24, Savil as modified teaches the claimed invention as described above (see claim 1, 9 and 17, respectively). Wu further teaches: determining an access permission in response to said second security context (Wu: Column 3 Line 11 – 14 and Column 6 Line 17 – 22. TABLE 1, Column 17 Line 40 – 44, Column 10 Line 33 – 35 and Column 19, Line 54 – 56).

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Longbit Chai whose telephone number is 703-305-0710. The examiner can normally be reached on Monday-Friday 8:00am-5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Ayaz R Sheikh can be reached on 703-305-9648. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Longbit Chai Examiner Art Unit 2131

LBC

AYAZ SHEIKH SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2100